

Ratcheting deformation in thin film structures

Z. SUO

Princeton University

Work with

MIN HUANG, Rui Huang, Jim Liang, Jean Prevost

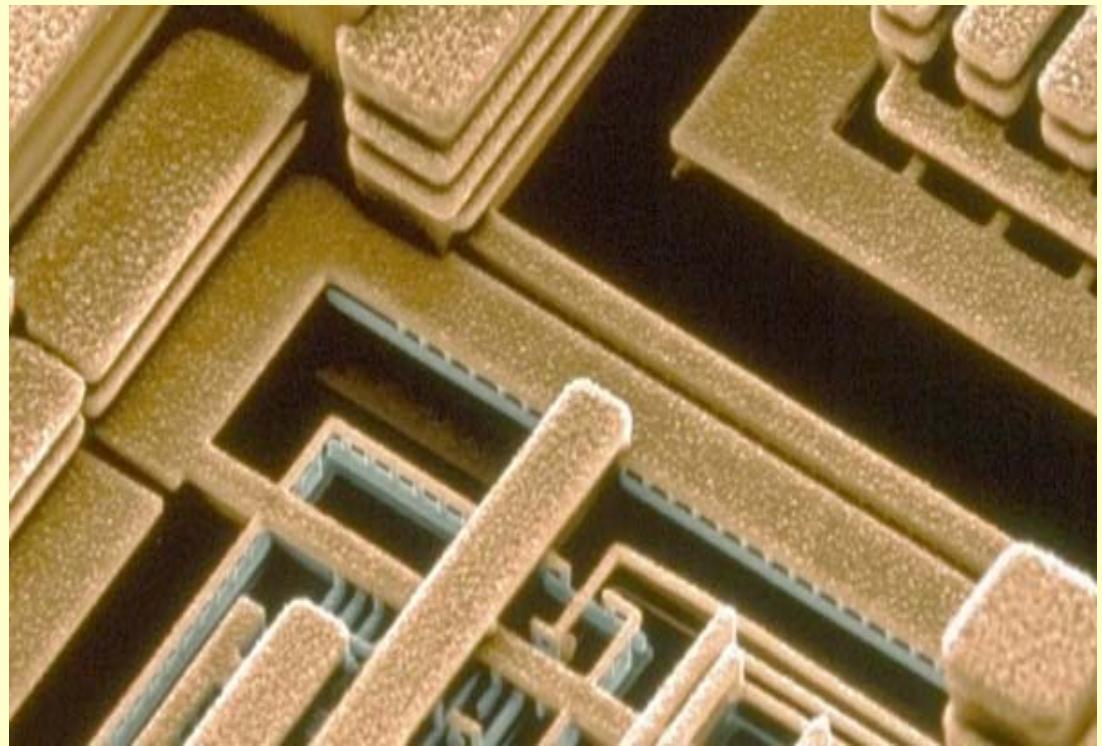
Princeton University

Q. MA, H. Fujimoto, J. He

Intel Corporation

Interconnect Structures

- Complex architecture
- Small feature sizes
- Diverse materials

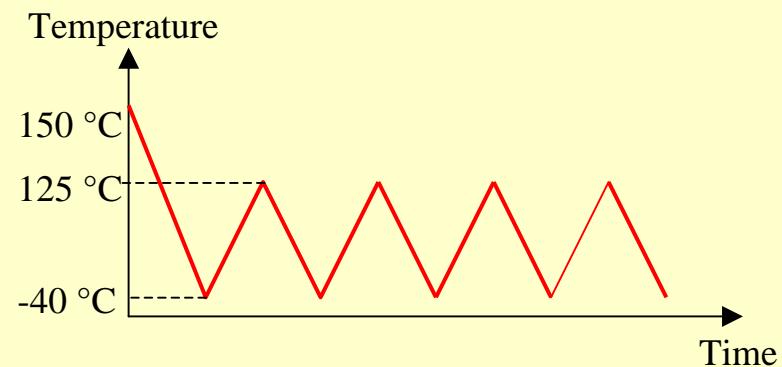
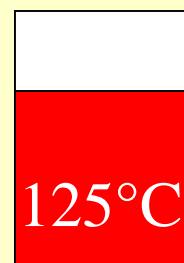
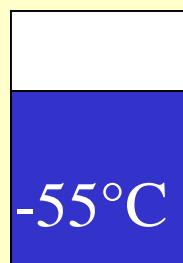


Intel: 130nm technology

ibm.com

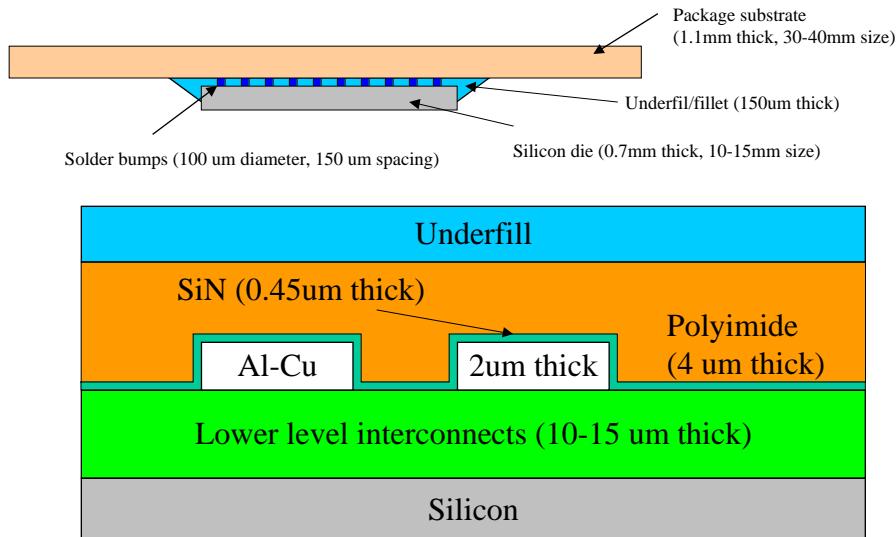
Thermal Cycling: Qualification Test

~1000 cycles

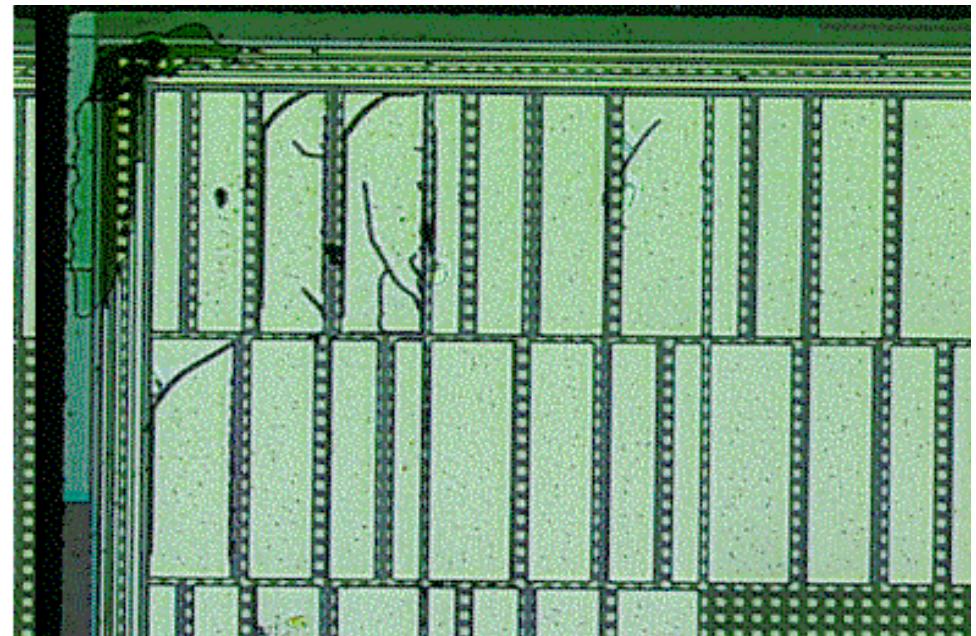
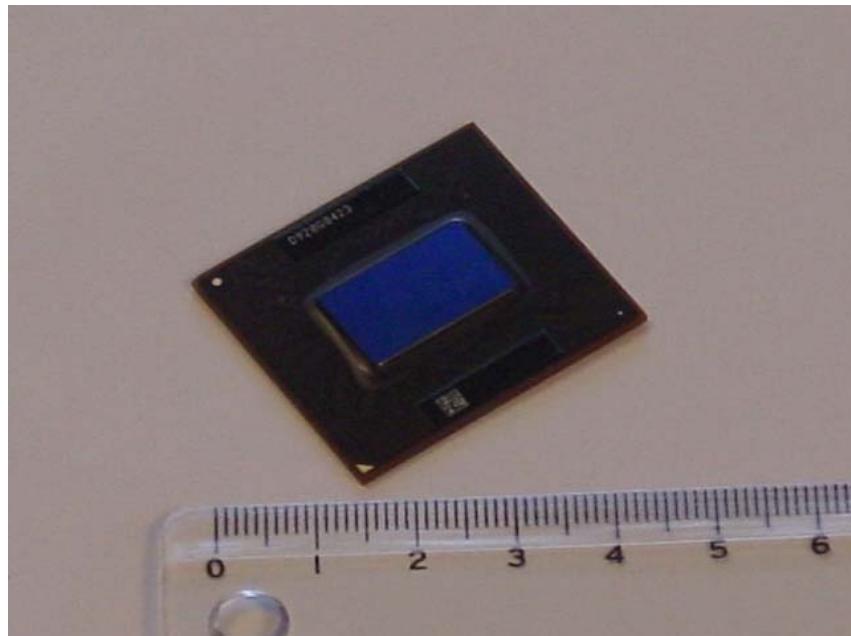


- Make-and-break
- Time consuming, a **bottleneck**
- Multiple failure modes
- Little understanding of mechanisms
- **New materials**

Flip-chip structure

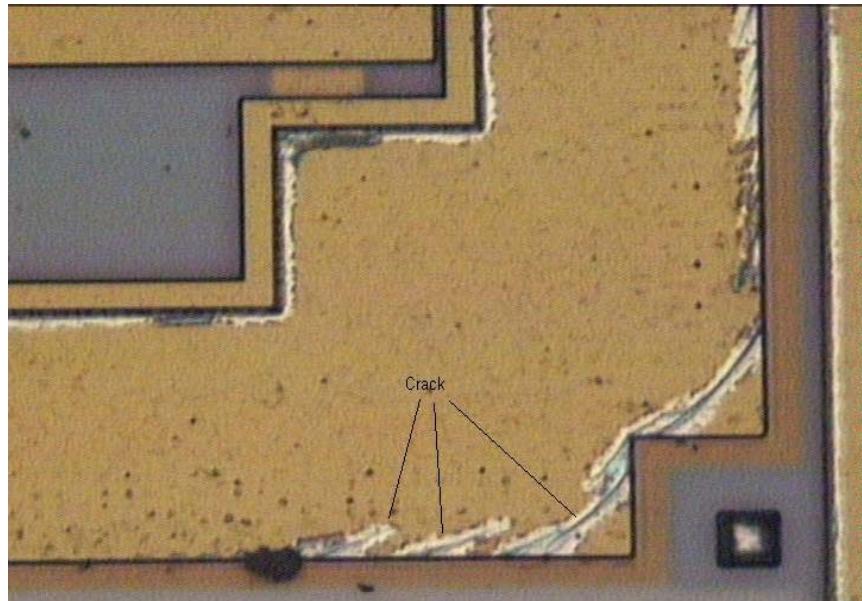


~1000 cycles

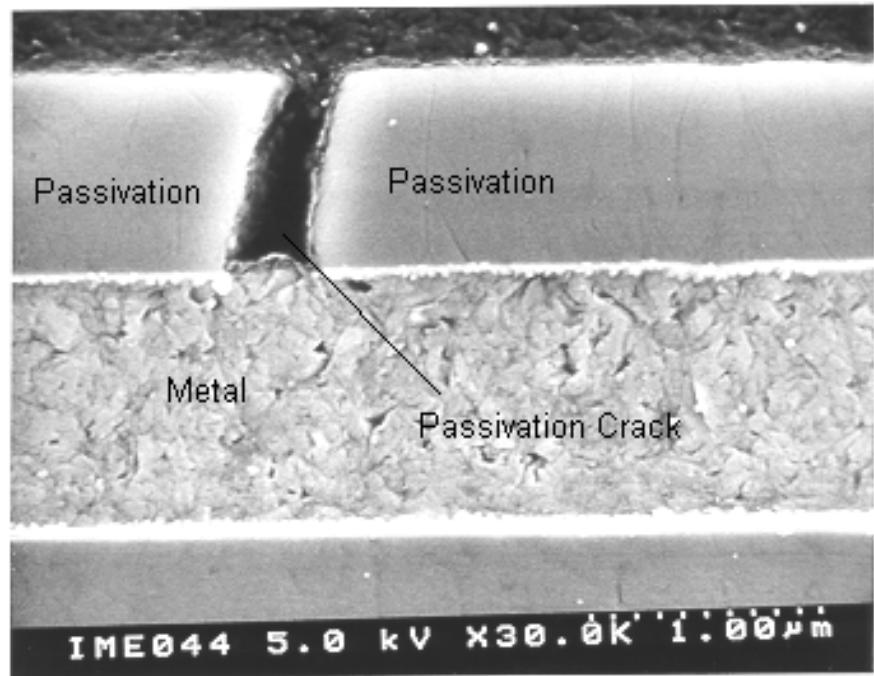


500 cycles between -55°C and 125°C

Plan view



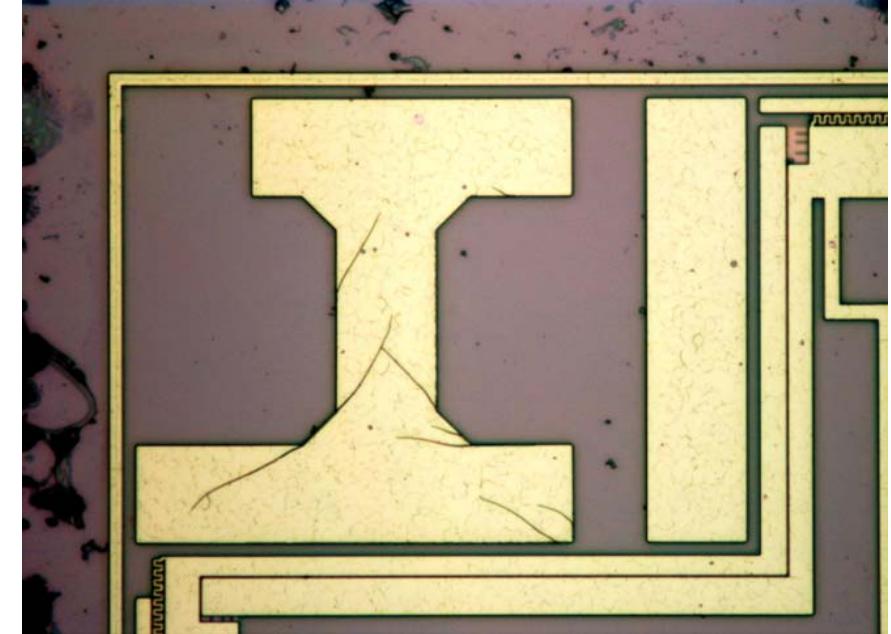
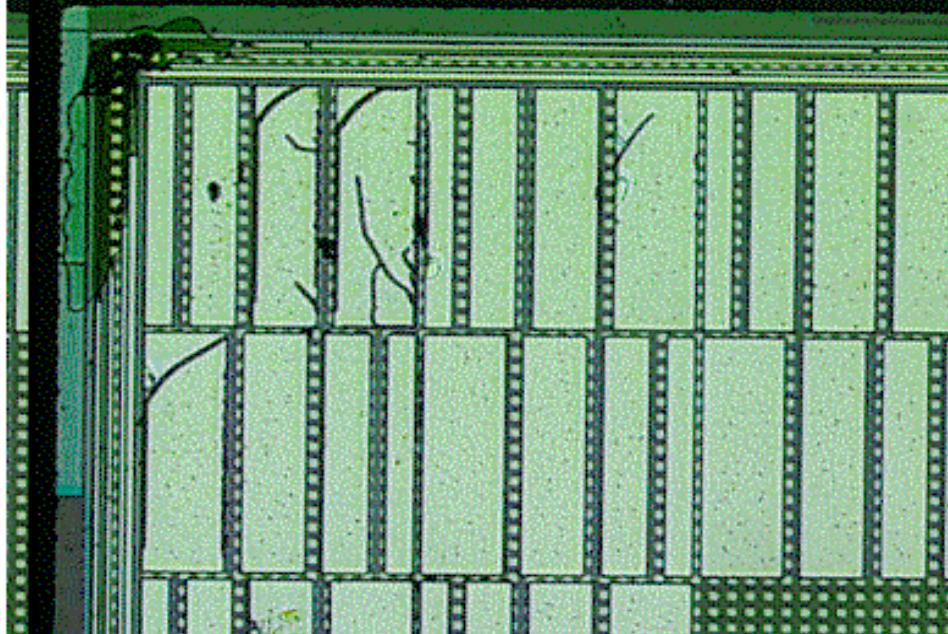
Edge view



Courtesy of Dr. J.B. Han , Agilent Technologies Singapore

Empirical Observations of Cracking

- At die corners
- After temperature cycles
- In SiN film over Al pads, but not in SiN film over silica
- More likely when Al pad is wide

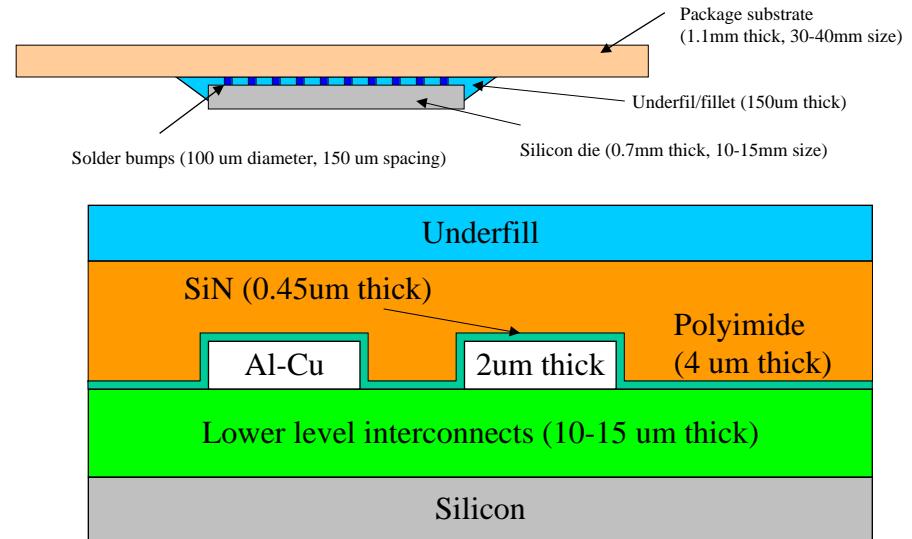


Questions

- **Why cycling?**
SiN does not fatigue

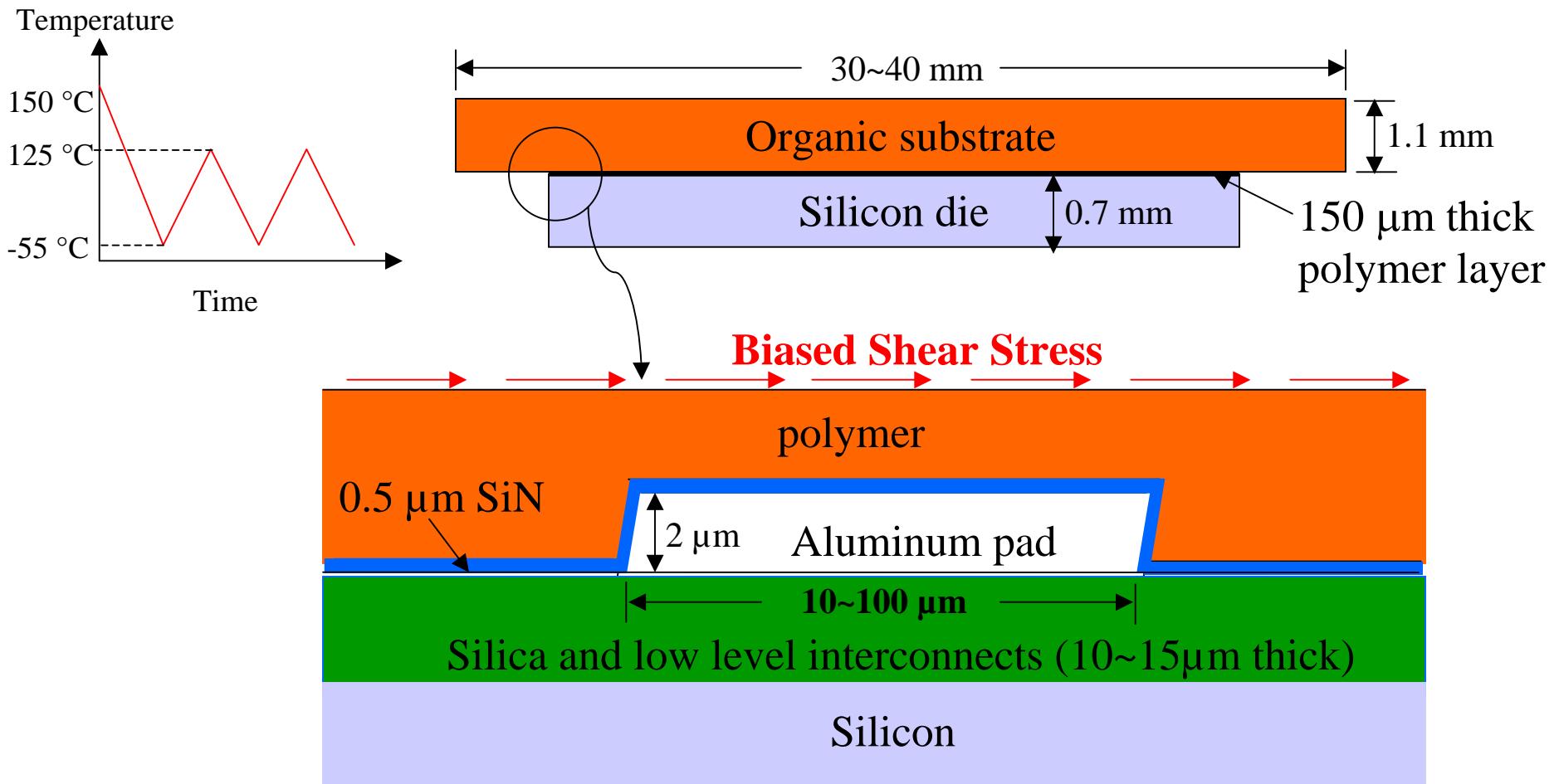
- **Why cracking?**
 - * Shear stress is limited by the yield strength of polymer, say 100 MPa.
 - * Breaking strength of SiN is 1000 MPa.

Flip-chip structure



Ratcheting Plastic Deformation

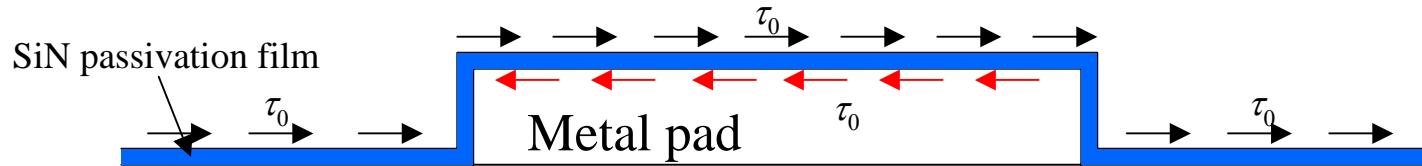
Huang, Suo, Ma, Fujimoto, *J. Mater. Res.*, **15**, 1239 (2000)



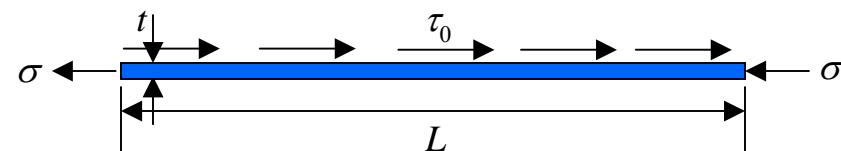
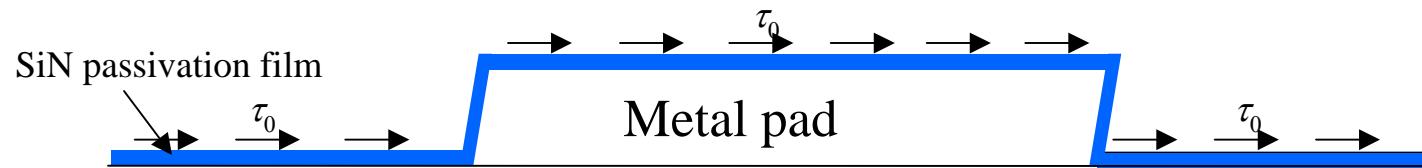
- Biased shear stress, from organic substrate
- Metal yields, from CTE mismatch with SiO_2

Stress builds up in SiN. STEADY STATE

First cycle



Many cycles, STEADY STATE



$$2\sigma t = \tau_0 L$$

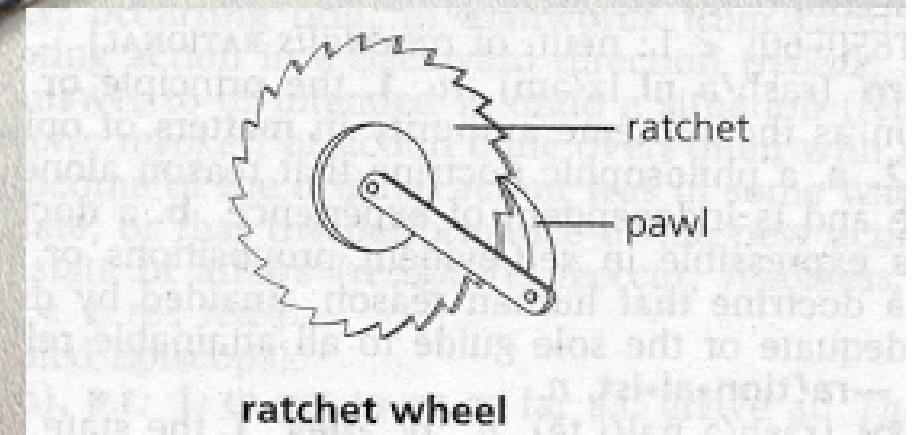
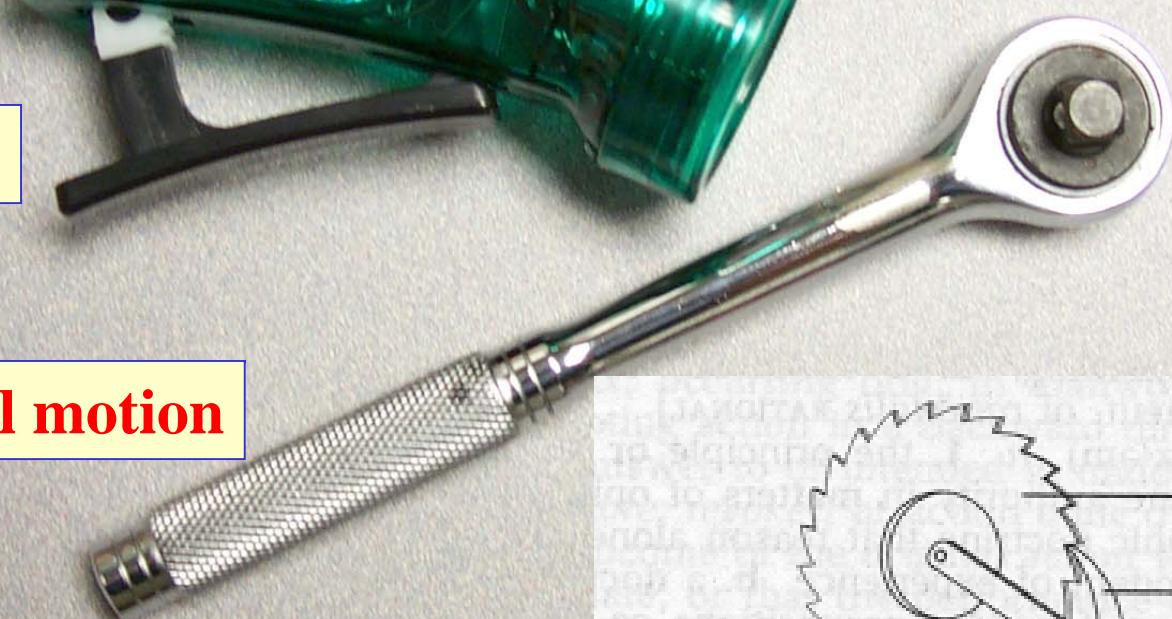
$$\sigma = \frac{\tau_0 L}{2t}$$

Ratchet and Pawl

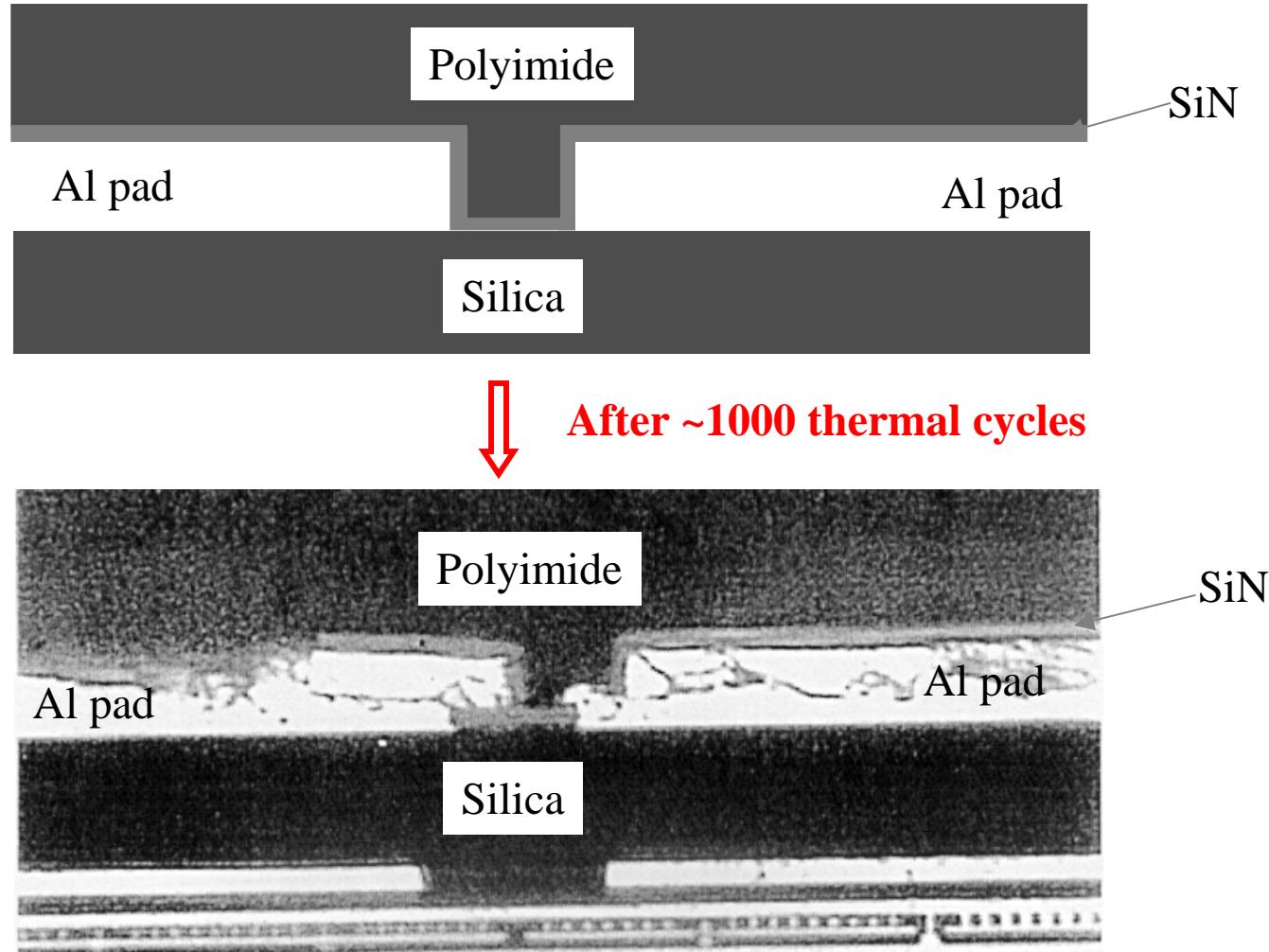
Cyclic motion



One-directional motion



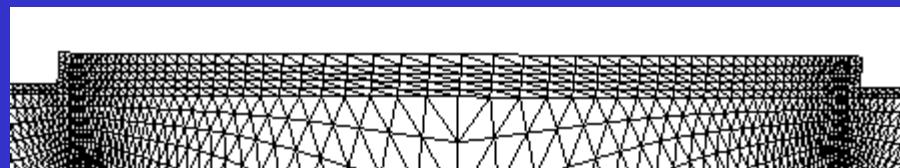
Metal Pad Crawling



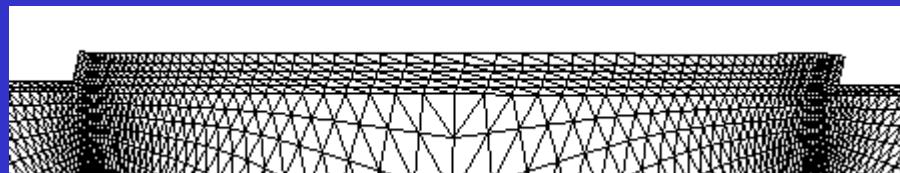
Large plastic deformation over many thermal cycles

Finite Element Simulation

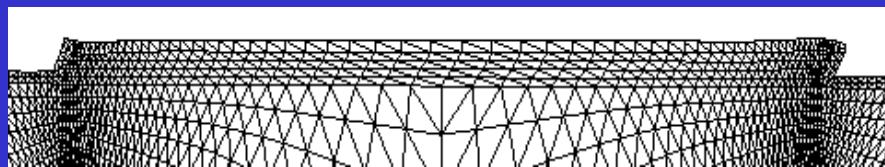
1 cycle



10 cycles



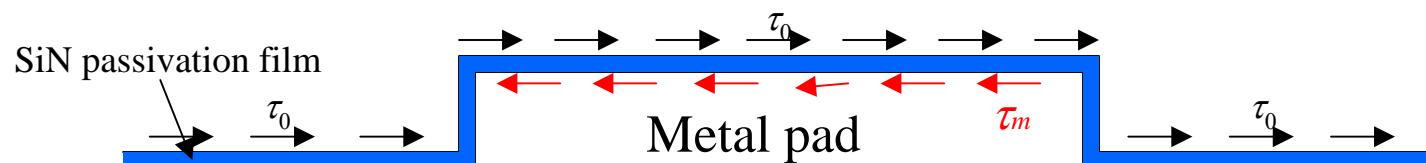
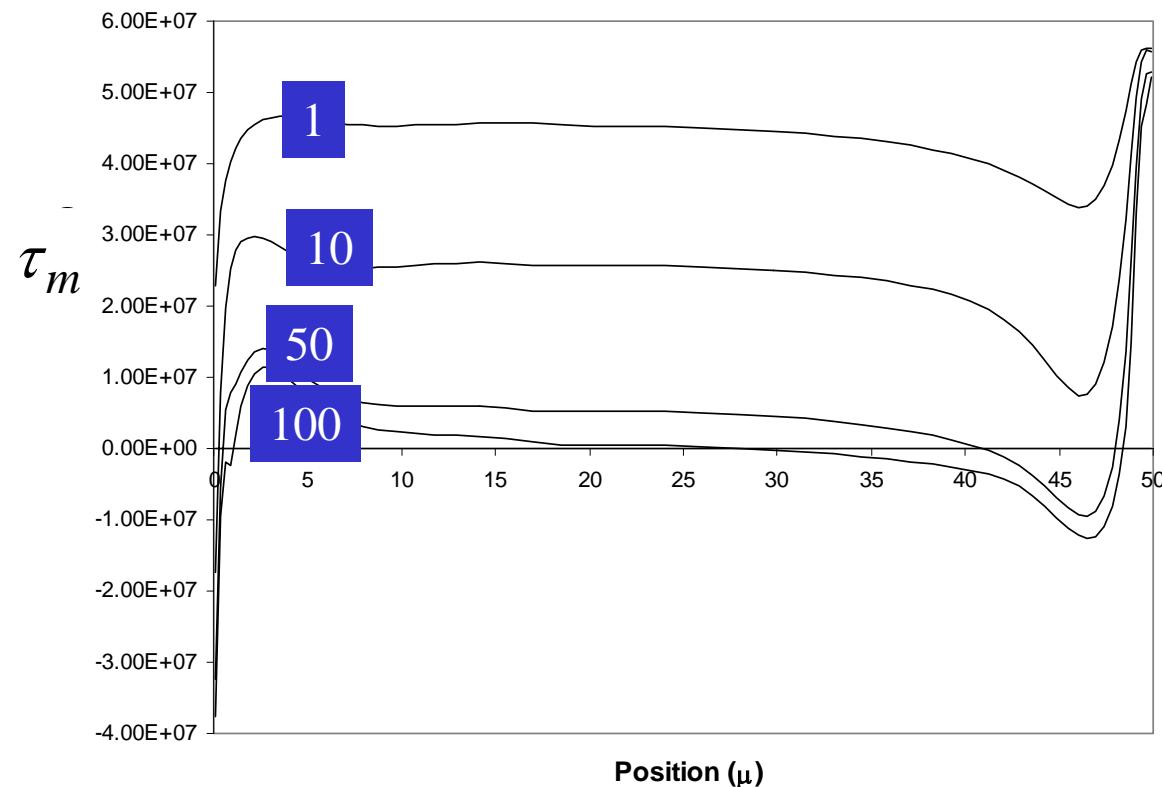
50 cycles



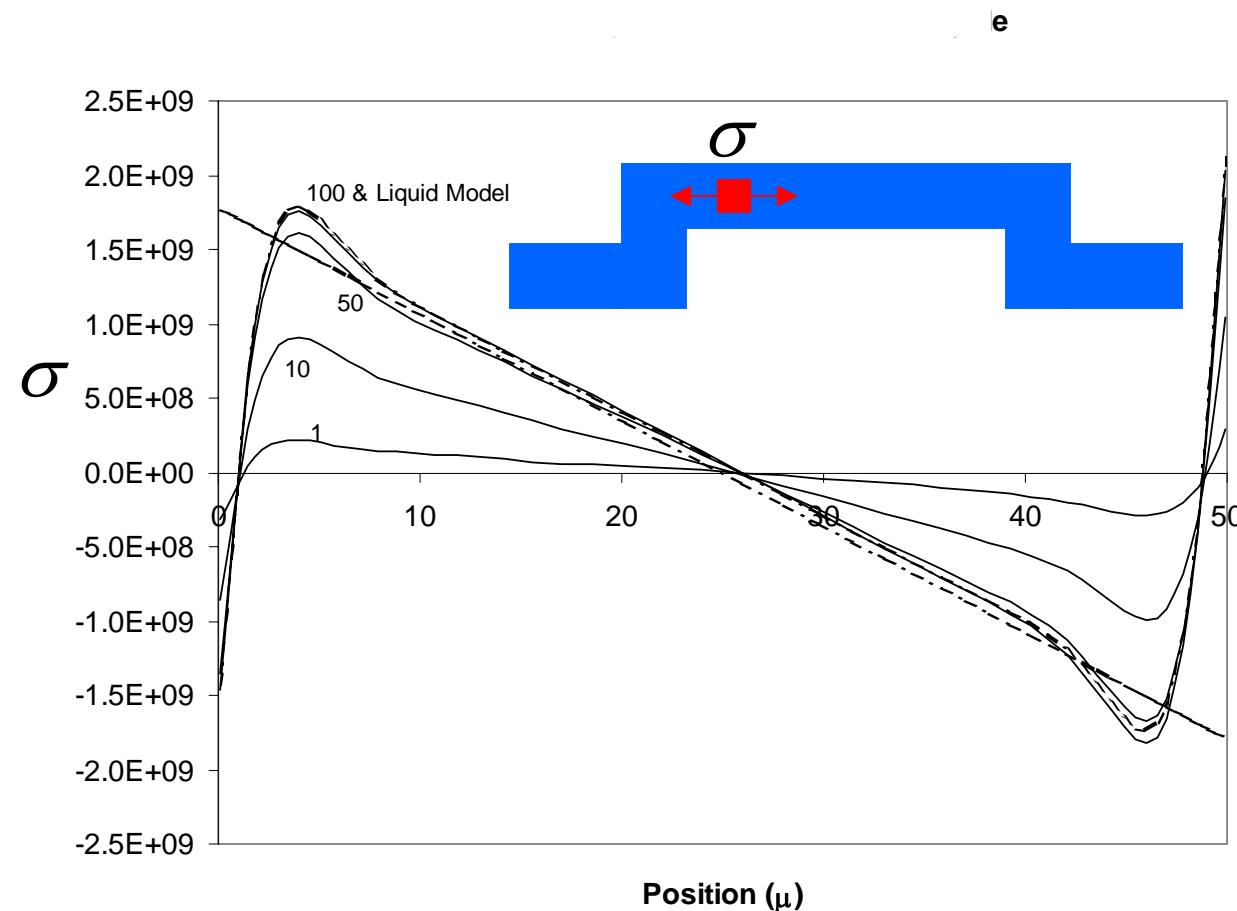
100 cycles



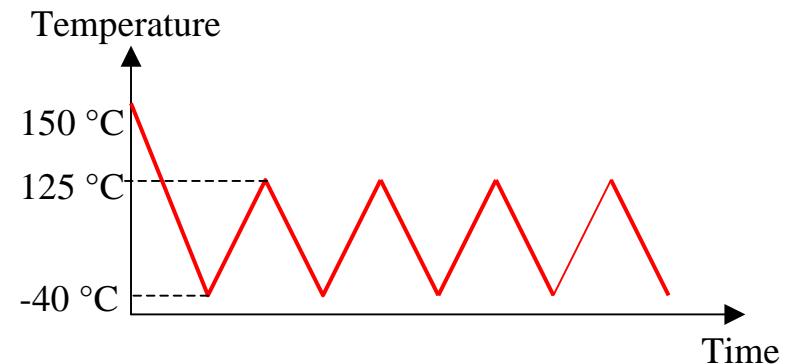
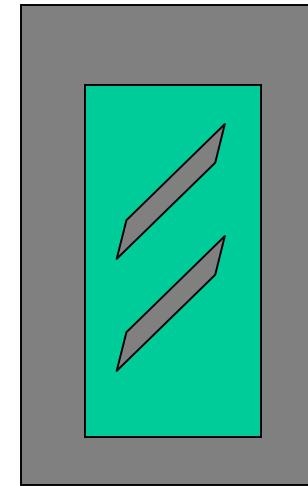
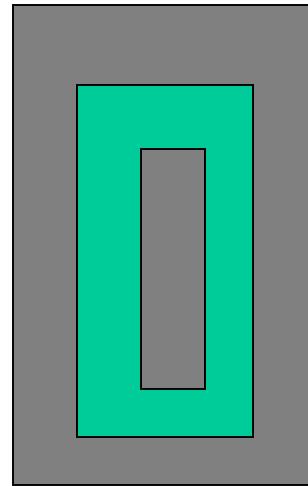
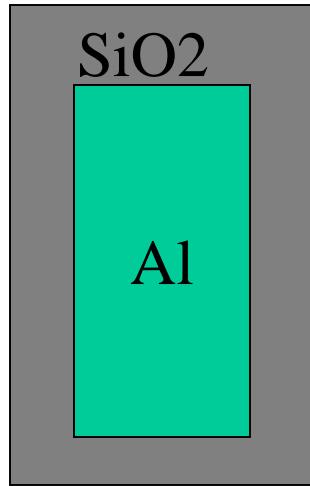
Shear stress in metal relaxes as temperature cycles



Membrane stress in SiN builds up as temperature cycles



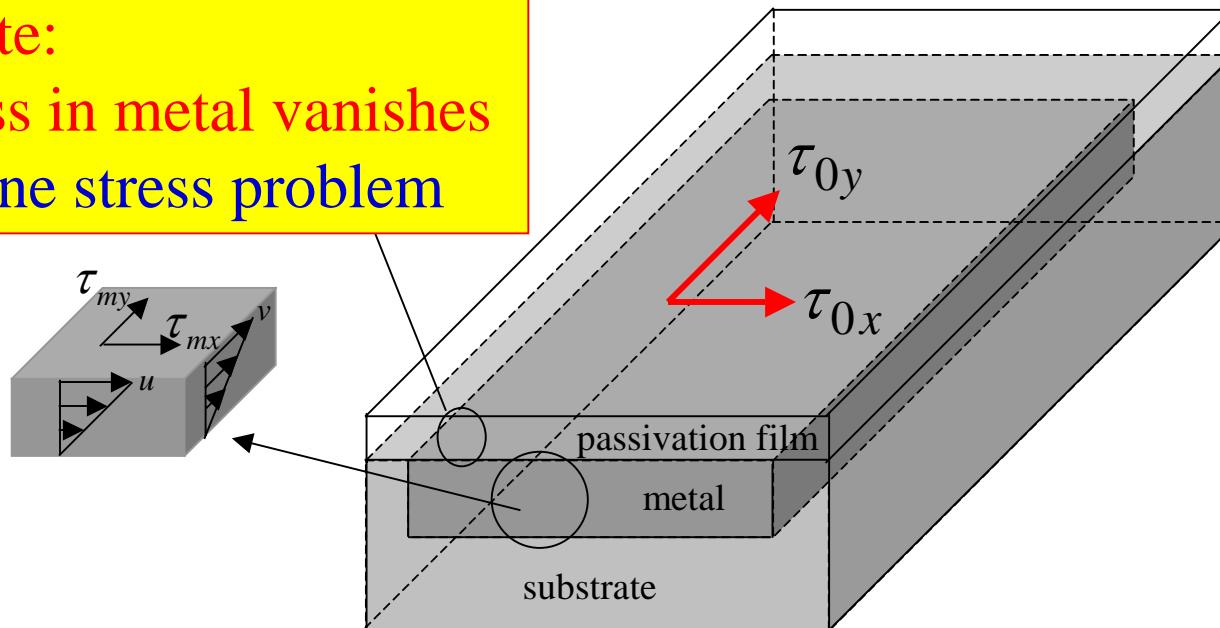
Metal pad geometry. Slots.



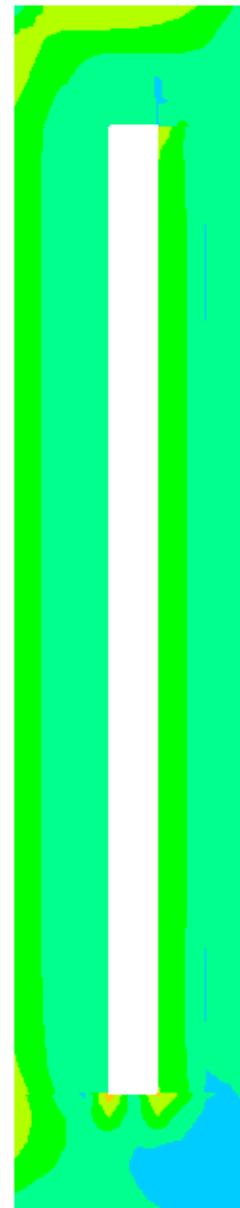
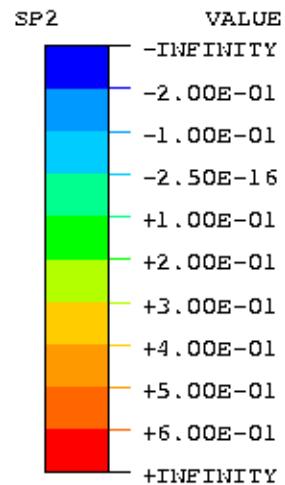
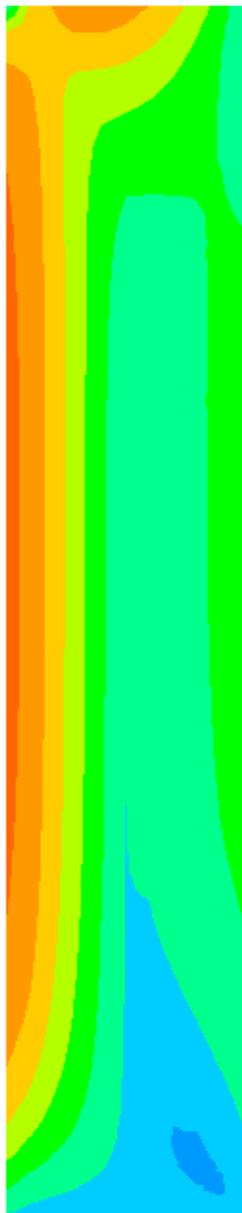
- Direct finite element calculations for 3D, many cycles take VERY long time.

3D Structure

Steady-state:
Shear stress in metal vanishes
Elastic plane stress problem



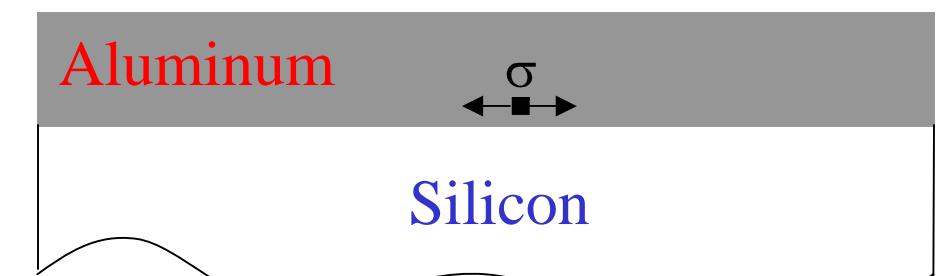
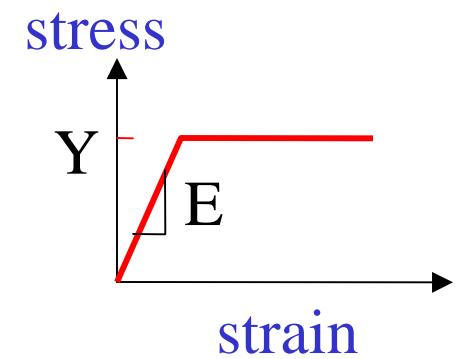
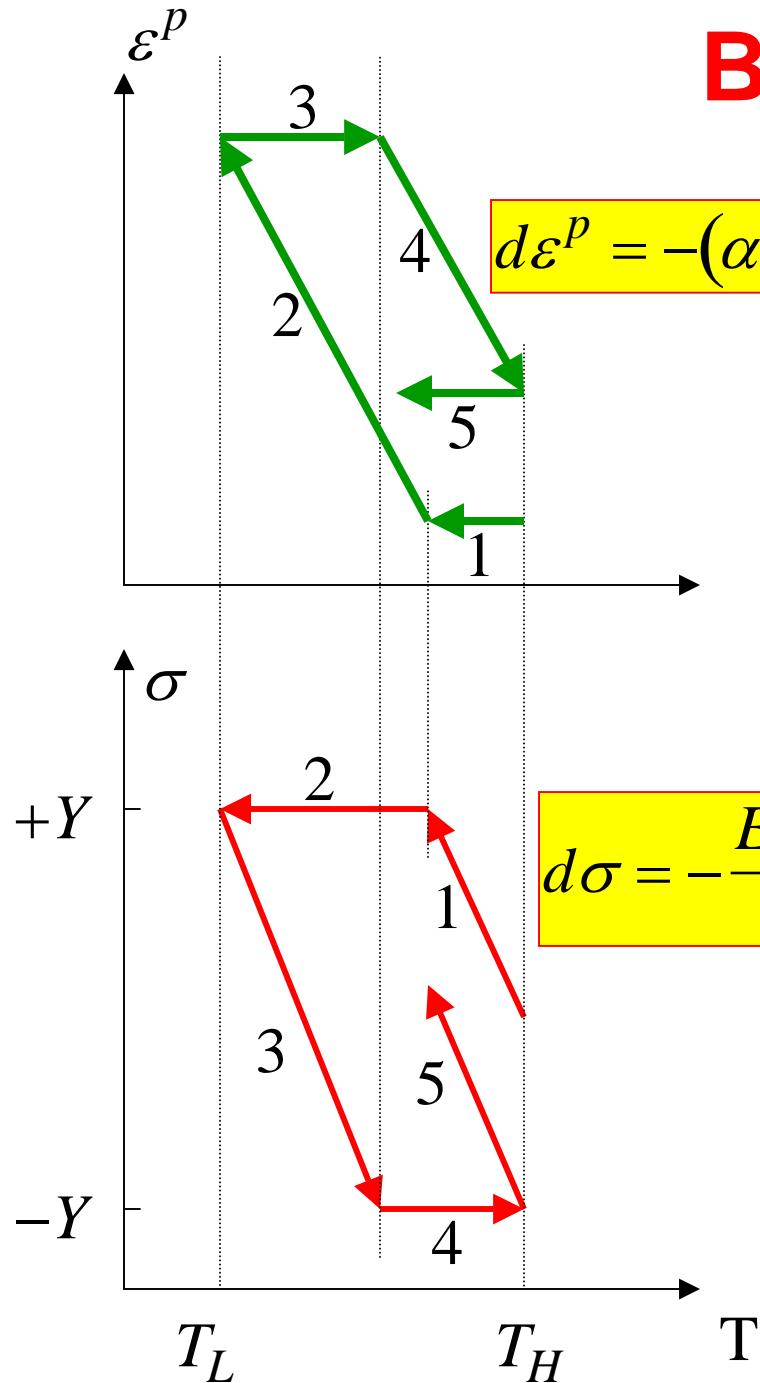
Slot!



Further Issues

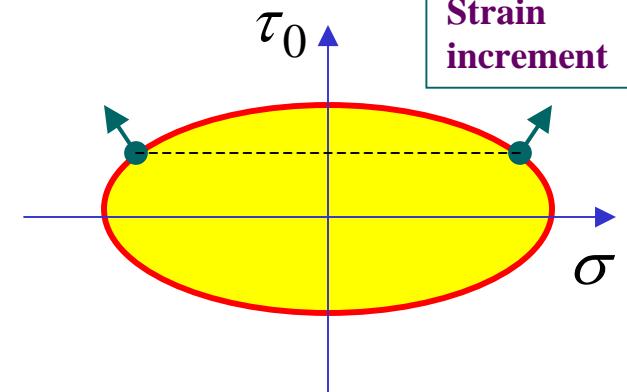
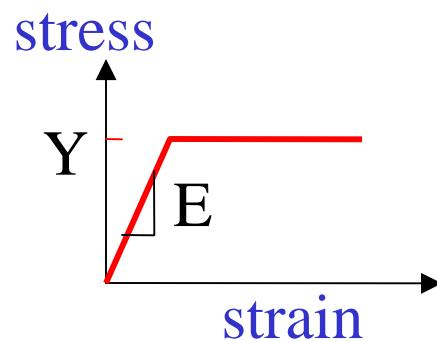
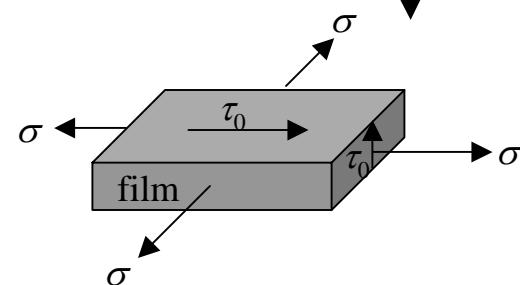
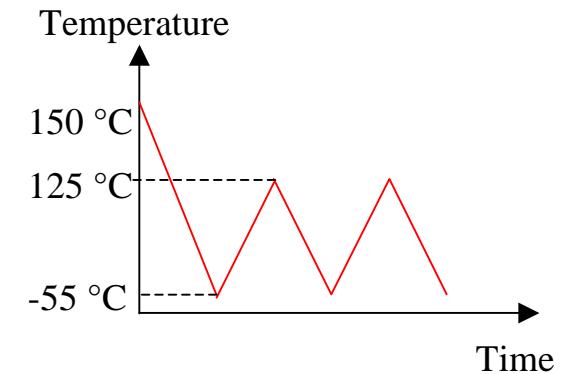
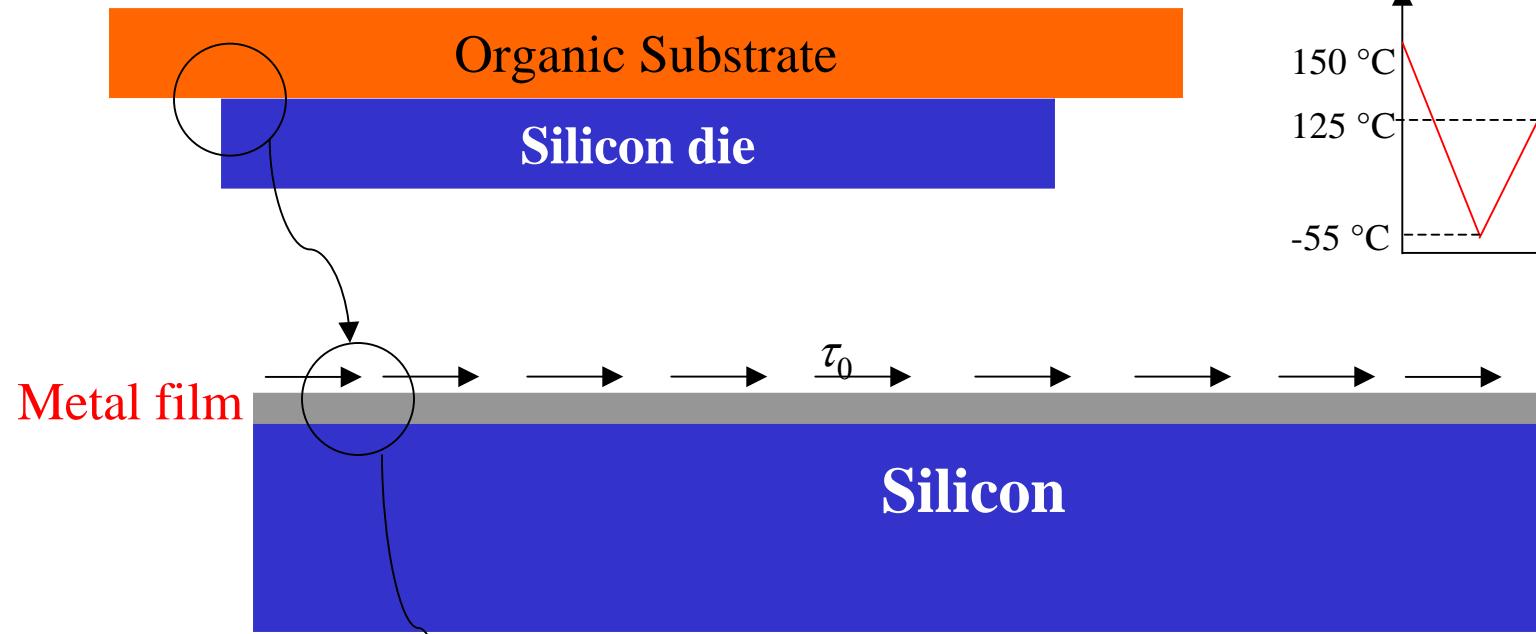
- Why cycle, again? Why not just plastic collapse?
- Number of cycles to approach the steady state.

Blanket film



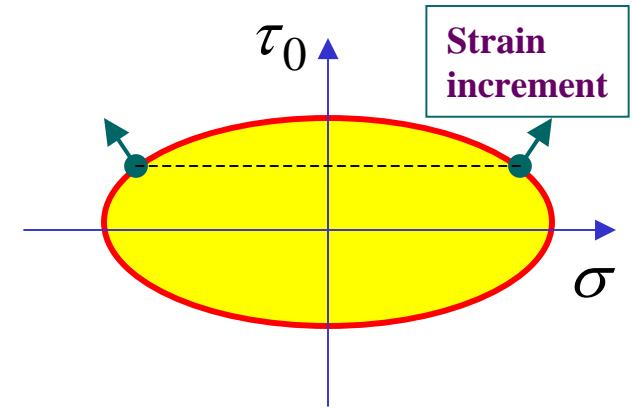
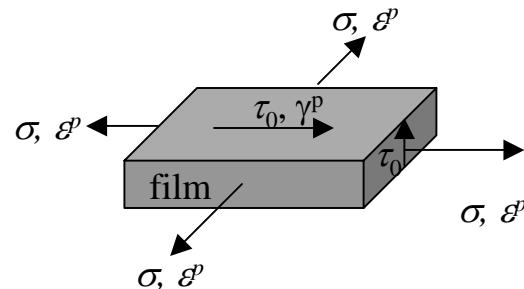
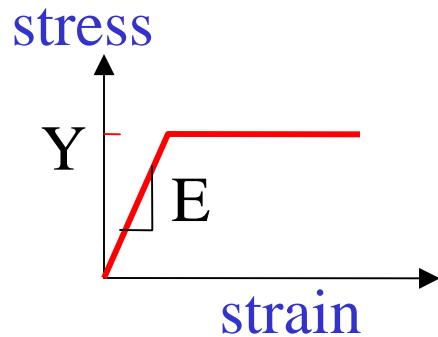
$$\frac{E(T_H - T_L)(\alpha_f - \alpha_s)}{(1 - \nu)Y} \begin{cases} > 2, & \text{cyclic plasticity} \\ < 2, & \text{shakedown} \end{cases}$$

Why Crawling?



Huang, Suo, Ma, *Acta Materialia*, **49**, 3039-3049 (2001)

Elastic-Plastic Model



Matching strains
of film & substrate

$$d\epsilon^p = -(\alpha_f - \alpha_s) dT$$

Yield condition

J2 flow theory

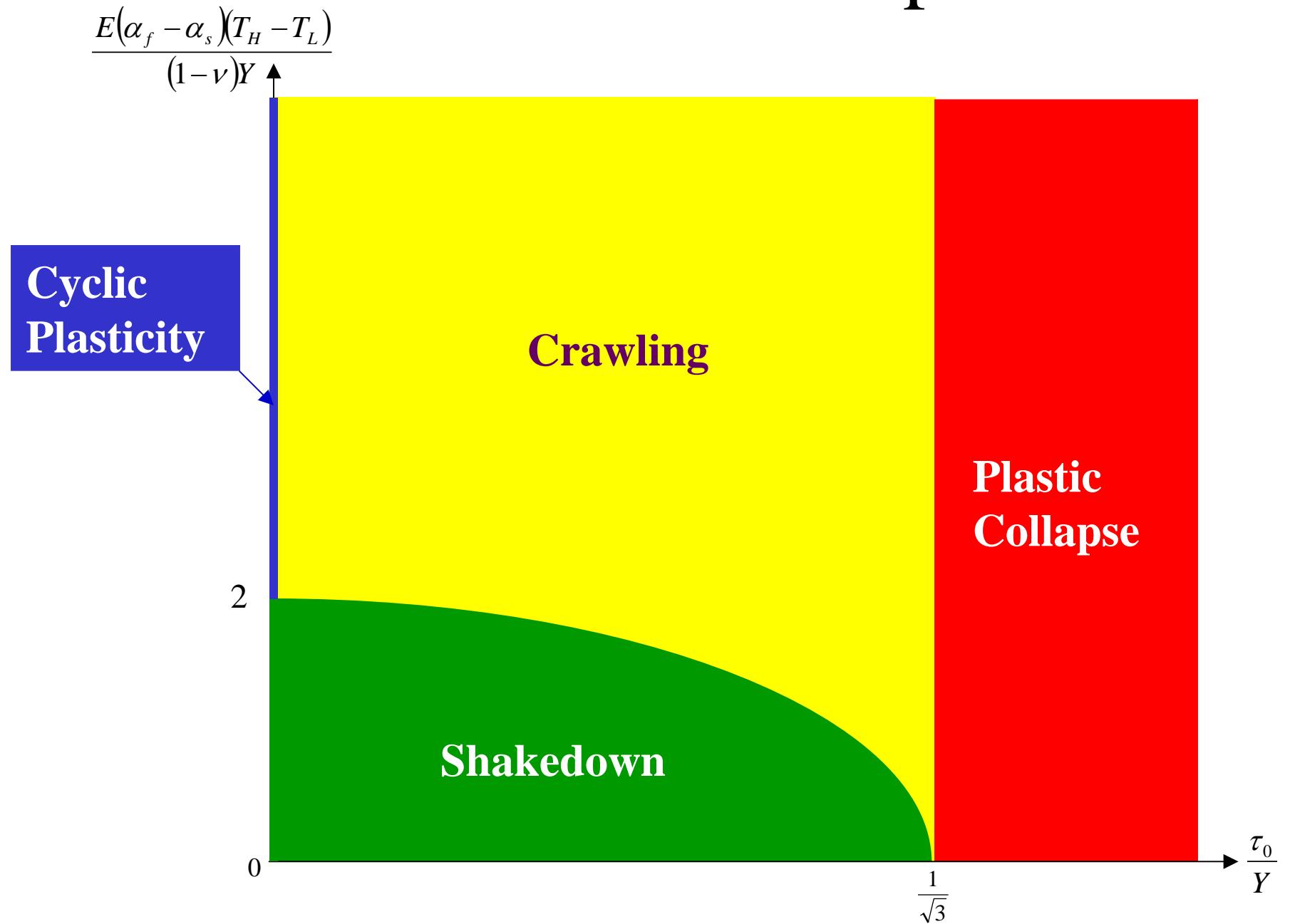
$$d\epsilon_{ij}^p = s_{ij} d\lambda$$

$$\frac{d\epsilon^p}{\sigma/3} = \frac{d\gamma^p}{2\tau_0}$$

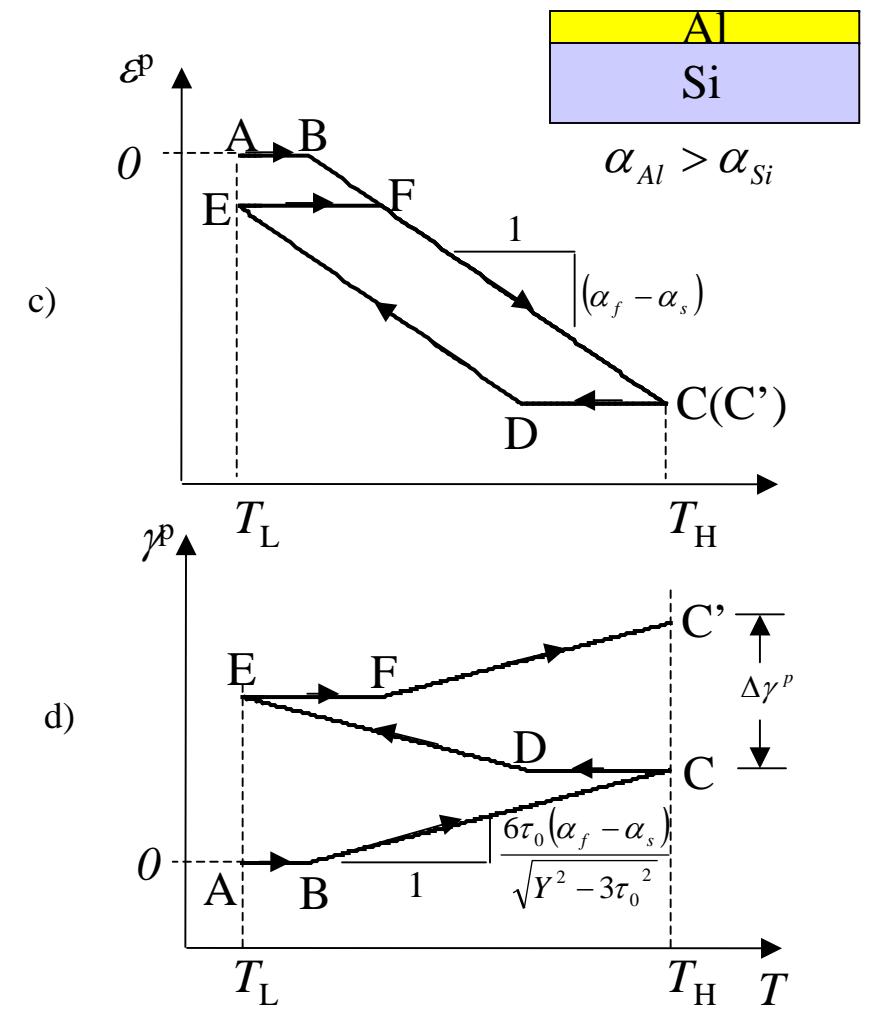
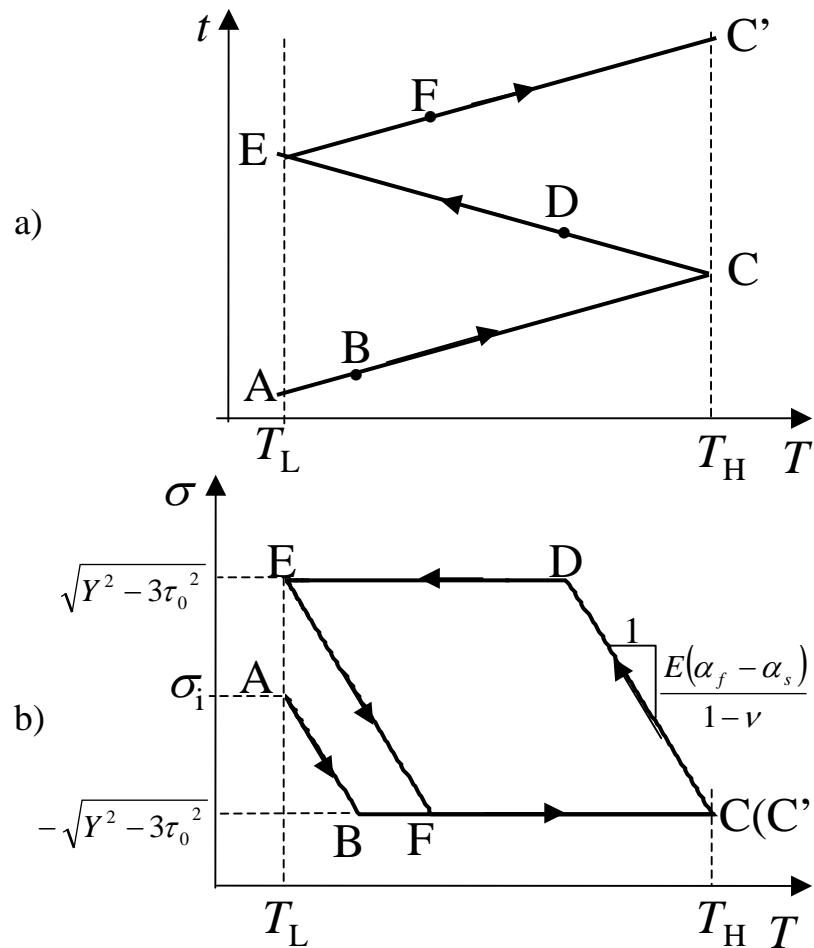
Shear strain increment

$$d\gamma^p = -\frac{6\tau_0}{\sigma} (\alpha_f - \alpha_s) dT$$

Four-color map



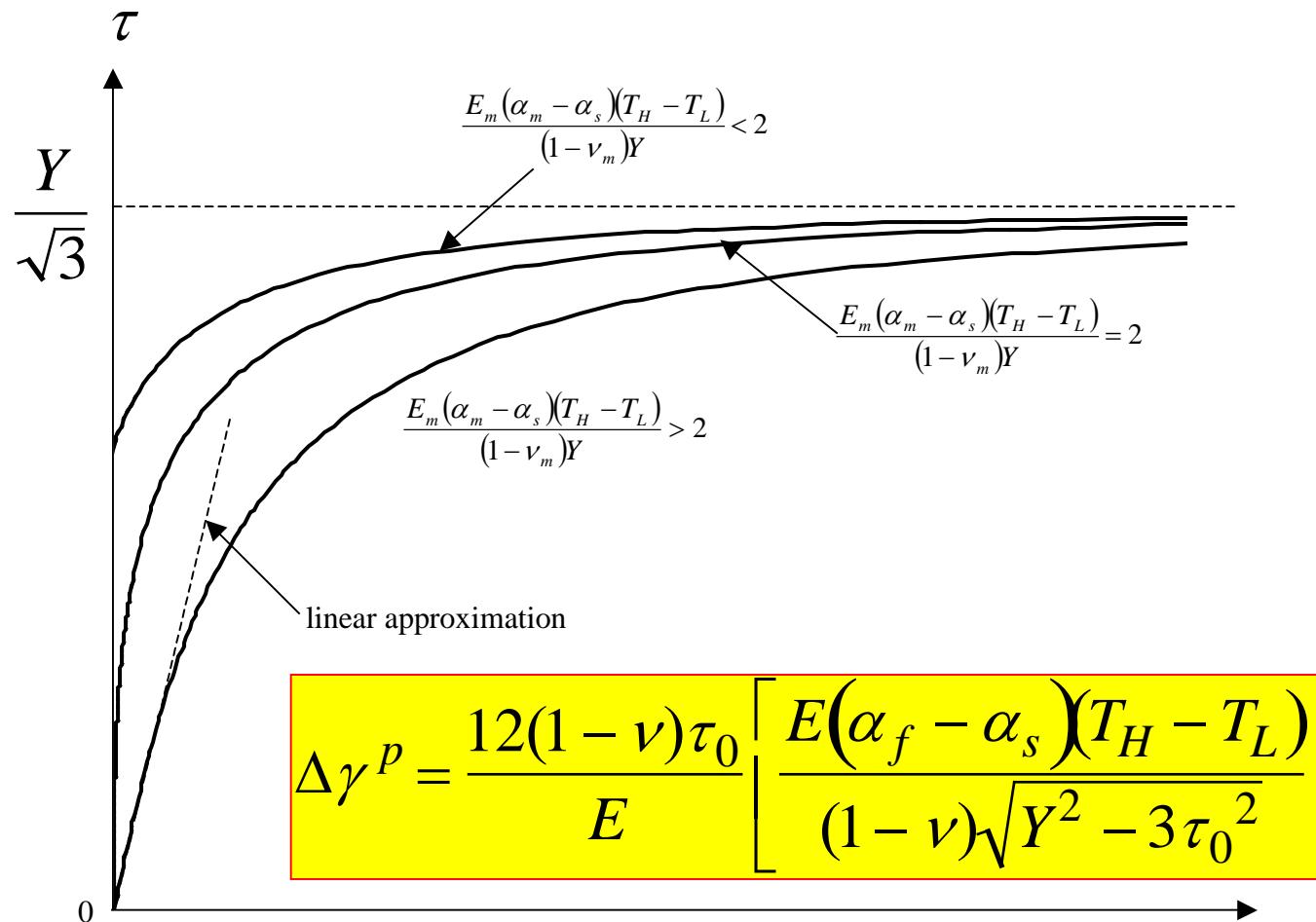
Stress and strain change with temperature



Strain per cycle

$$\Delta\gamma^p = \frac{12(1-\nu)\tau_0}{E} \left[\frac{E(\alpha_f - \alpha_s)(T_H - T_L)}{(1-\nu)\sqrt{Y^2 - 3\tau_0^2}} - 2 \right]$$

Ratcheting-Creep Analogy

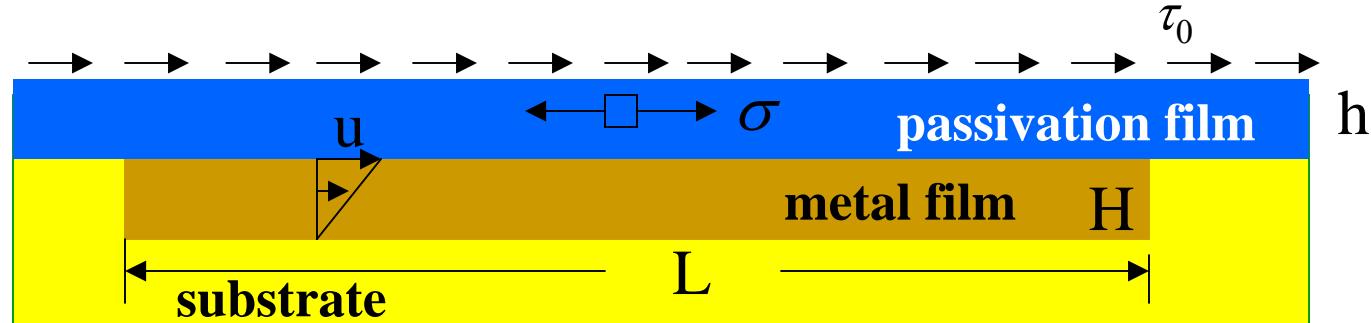


$$\Delta\gamma^p = \frac{12(1-\nu)\tau_0}{E} \left[\frac{E(\alpha_f - \alpha_s)(T_H - T_L)}{(1-\nu)\sqrt{Y^2 - 3\tau_0^2}} - 2 \right]$$

Strain per cycle $\Delta\gamma^p$

$$\frac{d\gamma}{dN} \Leftrightarrow \frac{d\gamma}{dt}$$

Number of cycles to reach steady-state



Elastic passivation film

$$\text{Equilibrium} \quad h \frac{\partial \sigma}{\partial x} = \tau - \tau_0$$

$$\text{Elasticity} \quad \sigma = E_p \frac{\partial u}{\partial x}$$

Ratcheting metal film

$$\tau = \frac{\eta}{H} \frac{\partial u}{\partial N}$$

$$\eta = \frac{E_m}{12} \left(\frac{E_m \Delta \alpha \Delta T}{Y} - 2 \right)^{-1}$$

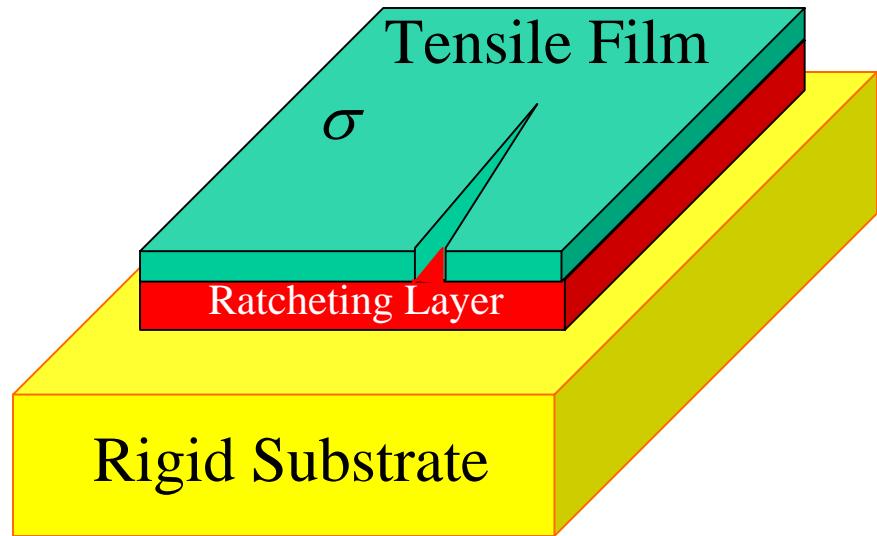
$$\frac{\partial u}{\partial N} = D \frac{\partial^2 u}{\partial x^2} - \frac{H \tau_0}{\eta}$$

$$D = \frac{EHh}{\eta}$$

$$N_0 \sim \frac{L^2}{D} \sim \frac{L^2}{Hh} \frac{E_m}{E_p} \left(\frac{E_m \Delta \alpha \Delta T}{Y} - 2 \right)^{-1}$$

Huang,Suo, Ma, *J Mech.Phys. Solids.* **50**, 1079 (2002)

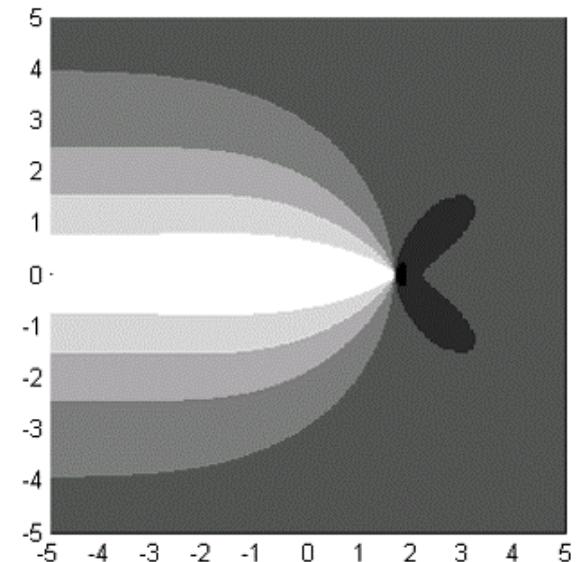
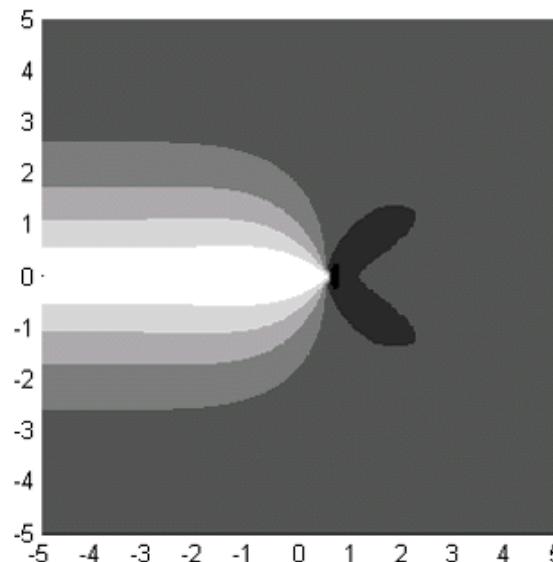
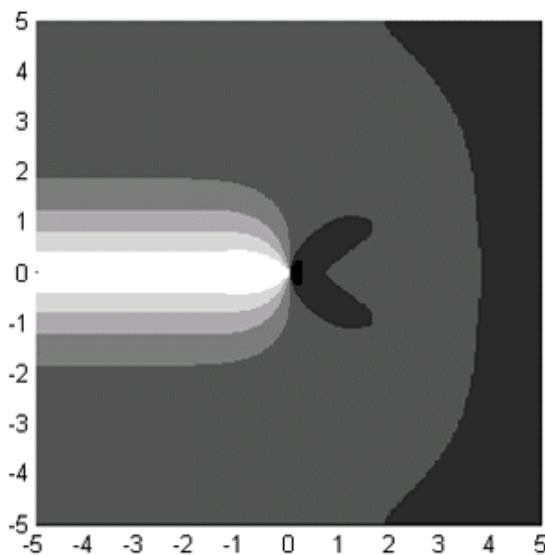
Concomitant crack extension and underlayer ratcheting



$$\frac{da}{dN} = 0.6 \frac{Hh\sigma^2}{\eta G_c}$$

$$\eta = \frac{E_m}{12(1-\nu_m)} \left[\frac{E_m \Delta \alpha \Delta T}{(1-\nu_m)Y} - 2 \right]^{-1}$$

J. Liang, R. Huang, J.H. Prevost, Z. Suo, submitted



Conclusions

- Thermal cycling test is a bottleneck.
- Ratcheting: cyclic temperature, aided by biased shear stress, causes uni-directional deformation.
- Stress relaxes in metal, and builds up in SiN.
- Ductile, low k dielectrics may ratchet.
- Need thin film data on large plastic deformation over many cycles, and long time.